

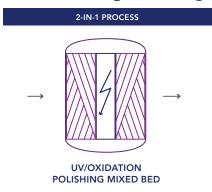
# **U-PUR**

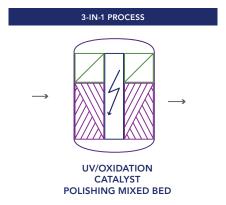
Designed and manufactured to meet challenging applications such as semiconductors, medical, pharmaceutical and all other industrial applications that exclusively require Ultrapure Water (UPW).

Conventional polishing systems include standalone UV's constructed of electro-polished stainless steel. The combination of the UV reactor and the polishing resin vessel enables the elimination of a potential source of contamination (oxidizable particles) within the polishing system.

This unique metal-free reactor also combines multiple UPW polishing steps for the removal of TOC and  $\rm H_2O_2$  traces. The 2-in-1 process step can easily be upgraded at any time to a 3-in-1 by adding a catalyst resin without further modification.

# Innovative polishing process





# Technical specifications

U-PUR		08	40
VESSEL DIAMETER	mm (inch)	460 (18.1)	1′000 (39.4)
HEIGHT (MAX.)	mm (inch)	2′500 (98.4)	3′300 (130)
TREATMENT CAPACITY	m³/h (gpm)	3 10 (13 44)	15 50 (65 220)
SERVICE PRESSURE (MAX.)	bar (psi)	6 (87)	
NUMBER OF UV LAMPS (185+254)		3	15
UV POWER	kW	1	5
ION EXCHANGE RESINS			
MIXED BED OvivUP® - M020	l (gal)	100 (26.4)	500 (132)
CATALYST CatOX™	l (gal)	60 (15.9)	300 (79.2)

### Ovivo Switzerland AG

Benkenstrasse 262, 4108 Witterswil, Switzerland

Ovivo is a global leader in water solutions for the semiconductor industry and stands as a founding member of the Semiconductor Climate Consortium (SCC), a pioneering initiative dedicated to fostering climate progress within the industry.

# Key features



STANDALONE SOLUTION

All process functions managed locally





#### **ULTRAPURE WATER COMPOSITION**

TOC < 1ppb $H_2O_2 < 1ppb$ 



#### LOW PRESSURE DROP

Less friction, simplified process



### **ENERGY EFFICIENT**

Power consumption optimization



### USER-FRIENDLY

Easy to operate, designed to facilitate servicing



## SHORT LEAD TIME

Less engineering, more flexibility

